

# Bunch diagnostics with coherent IR Undulator radiation Arik Willner, Universität Hamburg

### A new exciting instrument at FLASH ...



R-Undulator during test measurements

Some facts...

Why using the undulator instead of other techniques?

·Usual coherent diagnostics use broadband spectra

•short wavelength regime most interesting! ·narrow band source Being able to tune the undulator to a certain wavelength



The IR-Undulator in the FLASH tunn

Formfactor -

Simulated

formfactor

gaussian (1) and G.Geloni et.al.

spectrum - K=40

[Desy 03-031

(2003)] (2),

and on-axis

Since summer 2007 a new diagnostic tool

Infrared Undulator you get radiation in

is implemented in FLASH. With the

the wavelength range  $(1-200)\mu$ m

infrared radiation.

This will give us the opportunity to

characterize the longitudinal bunch

profile of the short electron bunches

produced by FLASH in a manner similar to other frequency-domain techniques using

•Undulator: electromagnetic, 40mm gap, 9 periods of 40cm, 44 poles a maximum field of 1.18T (K = 44 @500MeV) •situated after FEL-undulator and before the electron dump

•By using the same bunch as FEL, VUV and infrared light naturally synchronized!! Opportunity for pump-probe-experiments.



Single Particle Spectrum Simulated spectrum for horizontal polarized component, K=10 and on-axis

Plots courtesy of Oliver Grimm

#### **References:**

- [1] A. Alfeev et.al., Simulations of Hamburg University Undulator for infrared coherent source, Dubna 2005
- [2]O. Grimm et.al., The infrared undulator project at the VUV-FEL, proceedings of the 27th international FEL conference p. 183-186, Stanford August 2005
- [3]O. Grimm et.al., Principles of Longitudinal Beam Diagnostics with Coherent Radiation, TESLA-FEL 2006-03, April 2006

·Diagnostic Port installed in experimental hall of Flash (access without restrictions)

•Set-Up flushed with nitrogen

·Dispersive Spectrometer will be in use (DSSM), covers range from 26µm to 170µm

·Aim is a better understanding of spectrum and tuning behavior

 Correlation between machine parameters and undulator Spectra

·Second step will be a prevacuum set-up

 Parasitic use of undulator under investigation



#### The Set-up

DSSM (dispersive Spectrometer)

Production of first order by reflective grating as filter, afterwards same grating in front of the mirror

#### Gratinas:

- 1. 7.9 p/mm covers 99-166 um: 2. 20 lp/mm covers 39-65µm 3. 30 lp/mm covers  $26-43\mu$ m
- (change by linear movers)

Beam will be prepared by optics not to have a diameter greater than 20mm



Total spectrum-K=10 (×1000 special bunch shape you get an spectrum in total 15 20 ncy (THz)

## Outlook...

(2)

·Installing prevacuum set-up in experimental hall to get more accurate spectra as soon as possible

Because of

undulator

(dominant

fundamental)

- After comissioning of new infrared beamline a port in the tunnel 10m behind the undulator will be available for intensity measurements.
- A prevacuum set-up will be installed with a movable pyro-detector Ideas: - characterizing the source
  - after spectrum is guiet understood: scan of the formfactor by tuning the undulator through whole range of wavelengths and measuring the intensity for each. Comparing with simulated single electron spectrum you can figure the form factor ->bunch profile